

## Motivation

- Fundamental understandings of EUV electron driven chemistry is needed for targeted material engineering
- Tools for interrogating the energy spectrum of electrons of EUV materials are needed
- Tools for predicting the electron energy spectrum is needed to speed up material development

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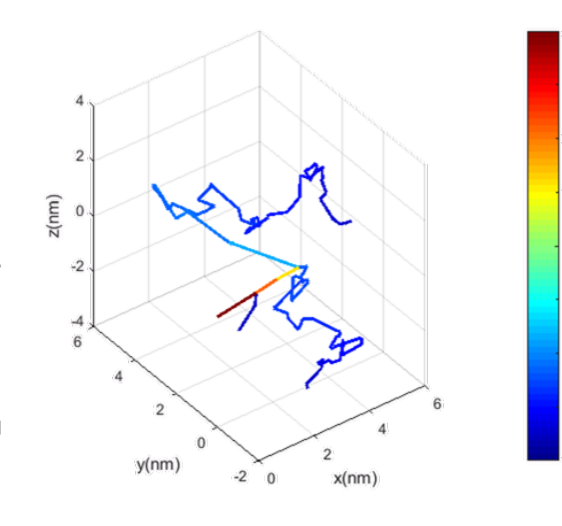
## Objectives

- Enables direct measurement of photoelectron energy spectrum of underlayers with condensed phase photoemission experiment
- Develop the capability to extract internal electron energy spectrum from photoemission spectrum
- Predict primary electron spectrum prediction
- Understand EUV induced chemical alterations during photoemission experiment

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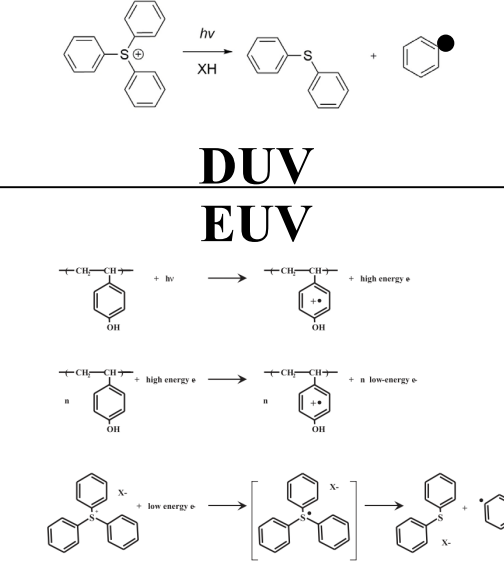
## The Problem

Simulated trajectory of a primary electron



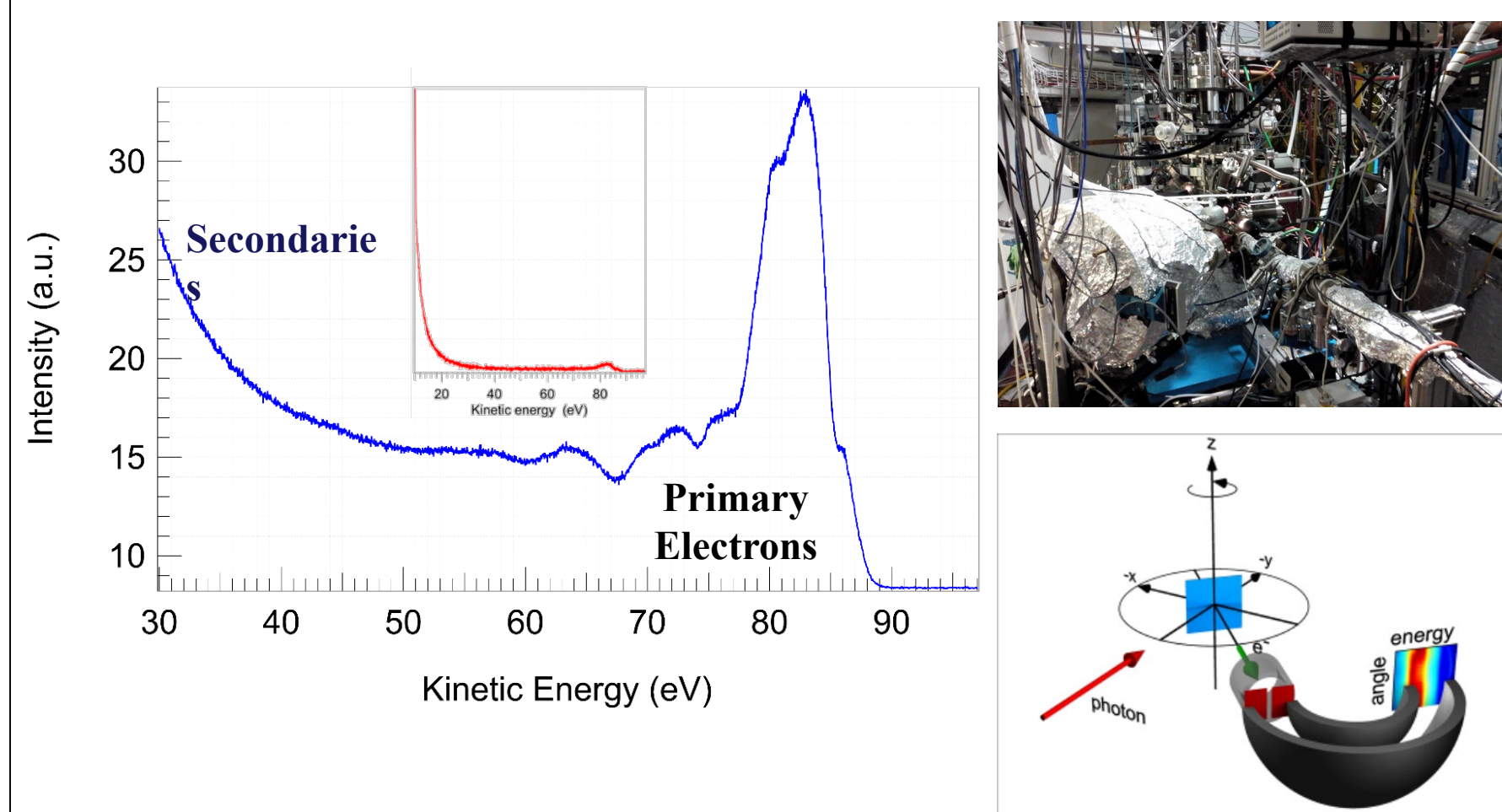
- EUV radiochemistry is electron driven
- Electron processes are yet to be understood
- Electrons' propensity to interact results in a broad spectrum of electrons in materials
- Difficult for scientific investigation or material engineering

PAG activation



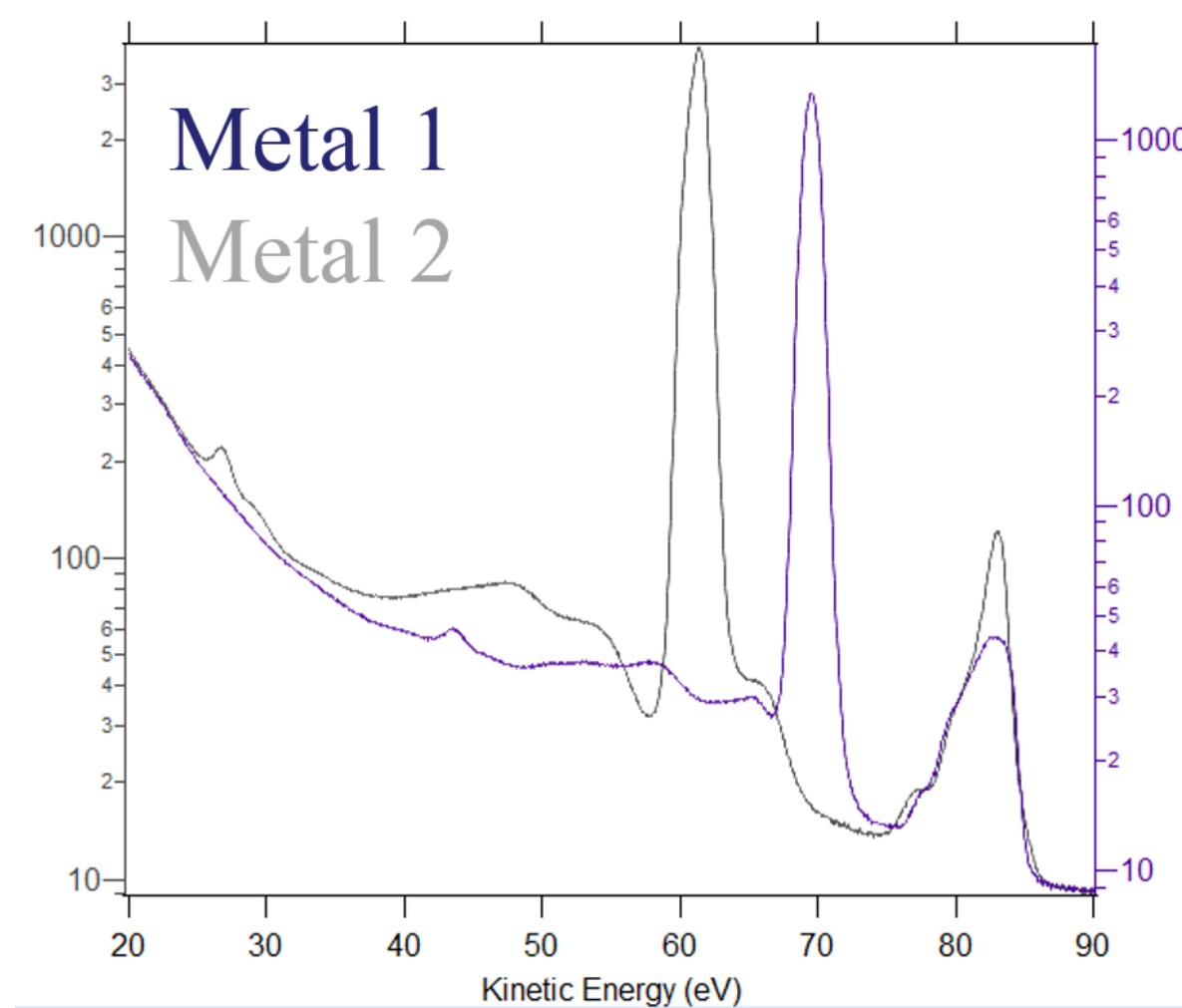
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## Condensed phase photoemission



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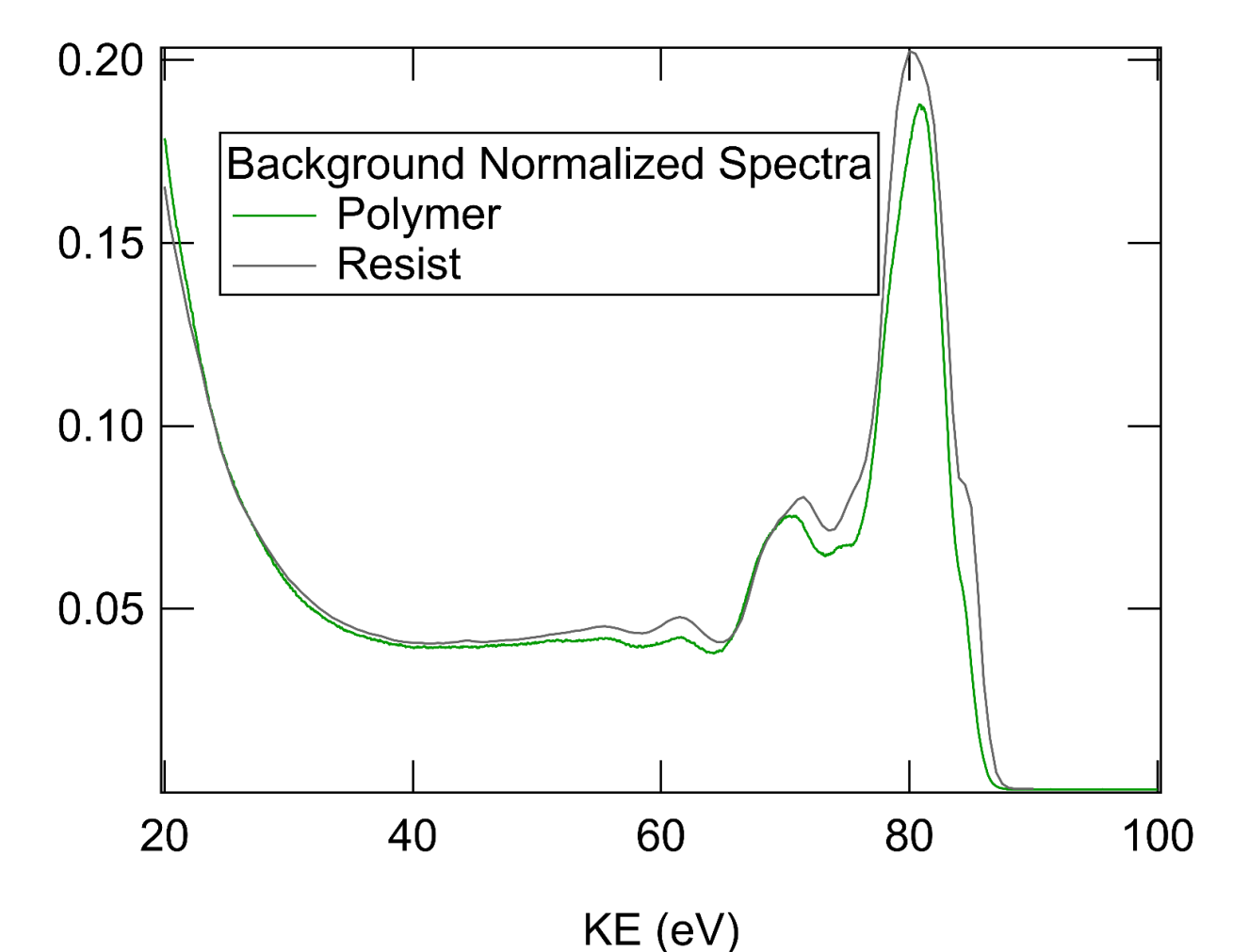
## Photoemission—underlayers



Ability to engineer primary electron spectrum is demonstrated

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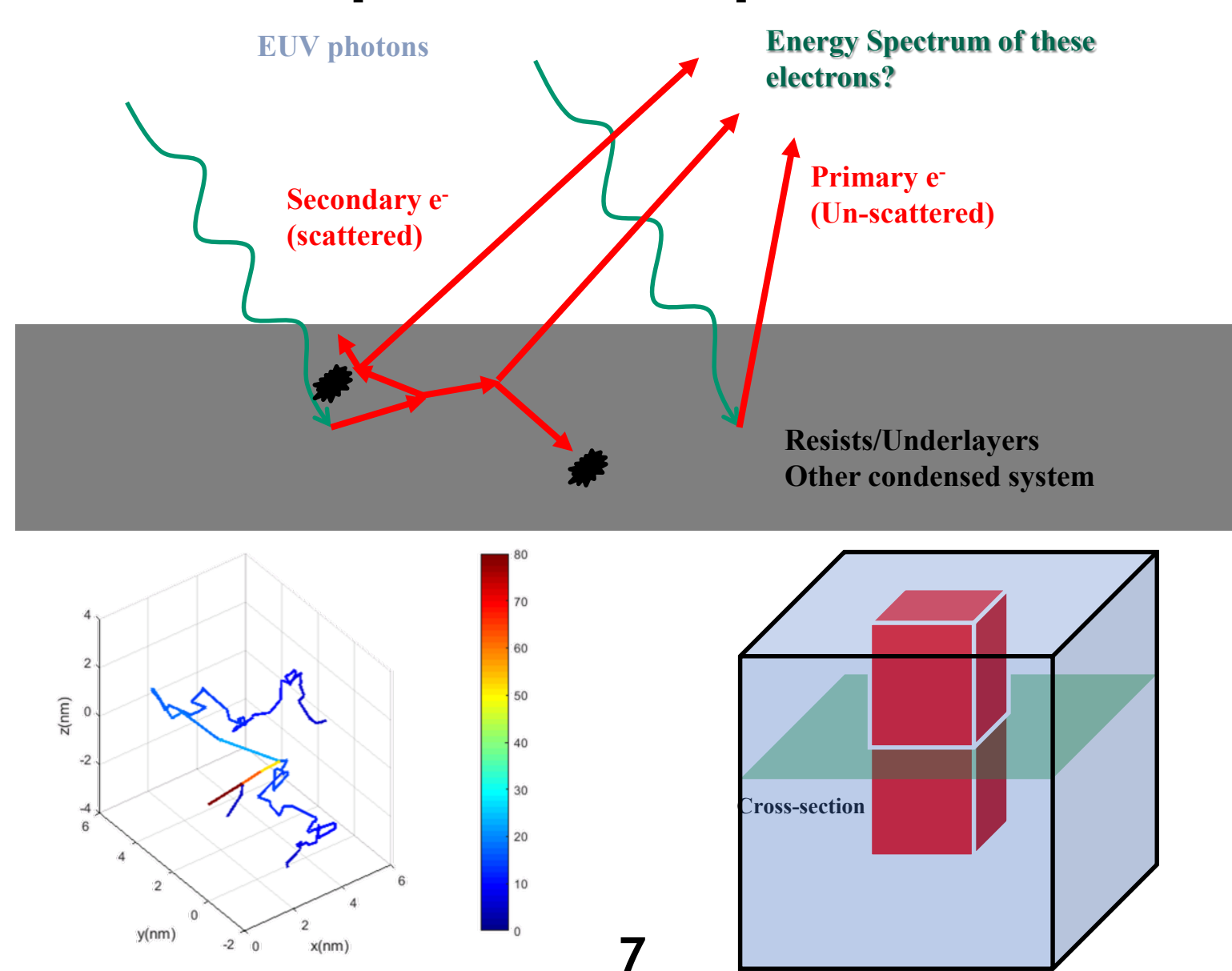
## Photoemission—resists



Photoelectrons are mostly from polymers

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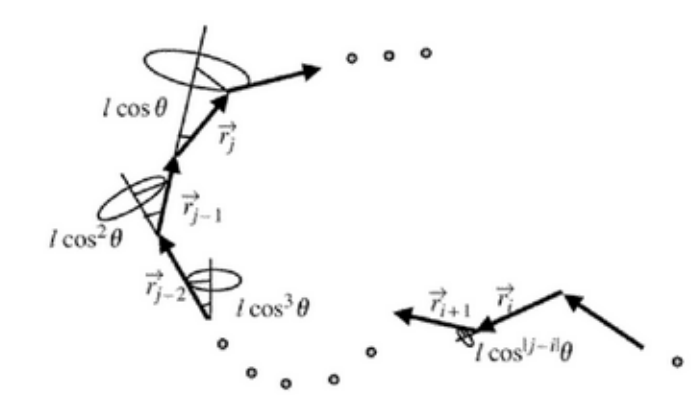
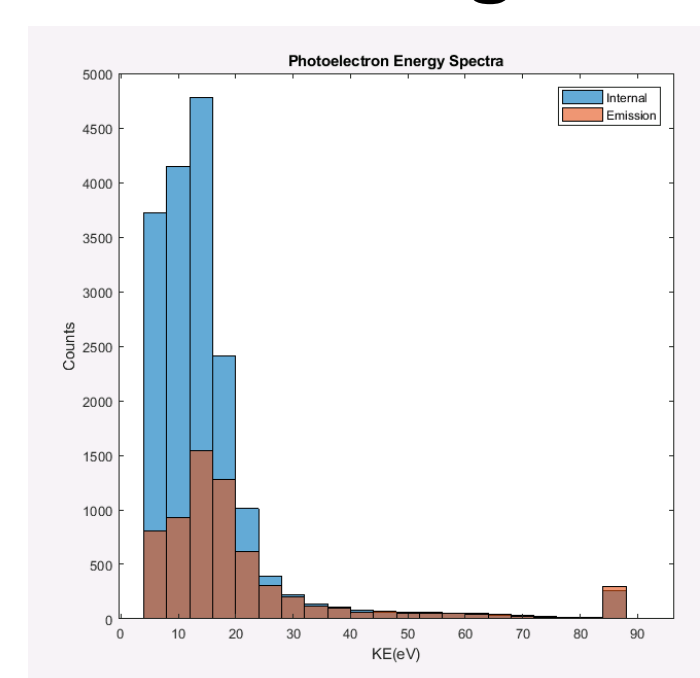
## Internal spectrum vs photoemission



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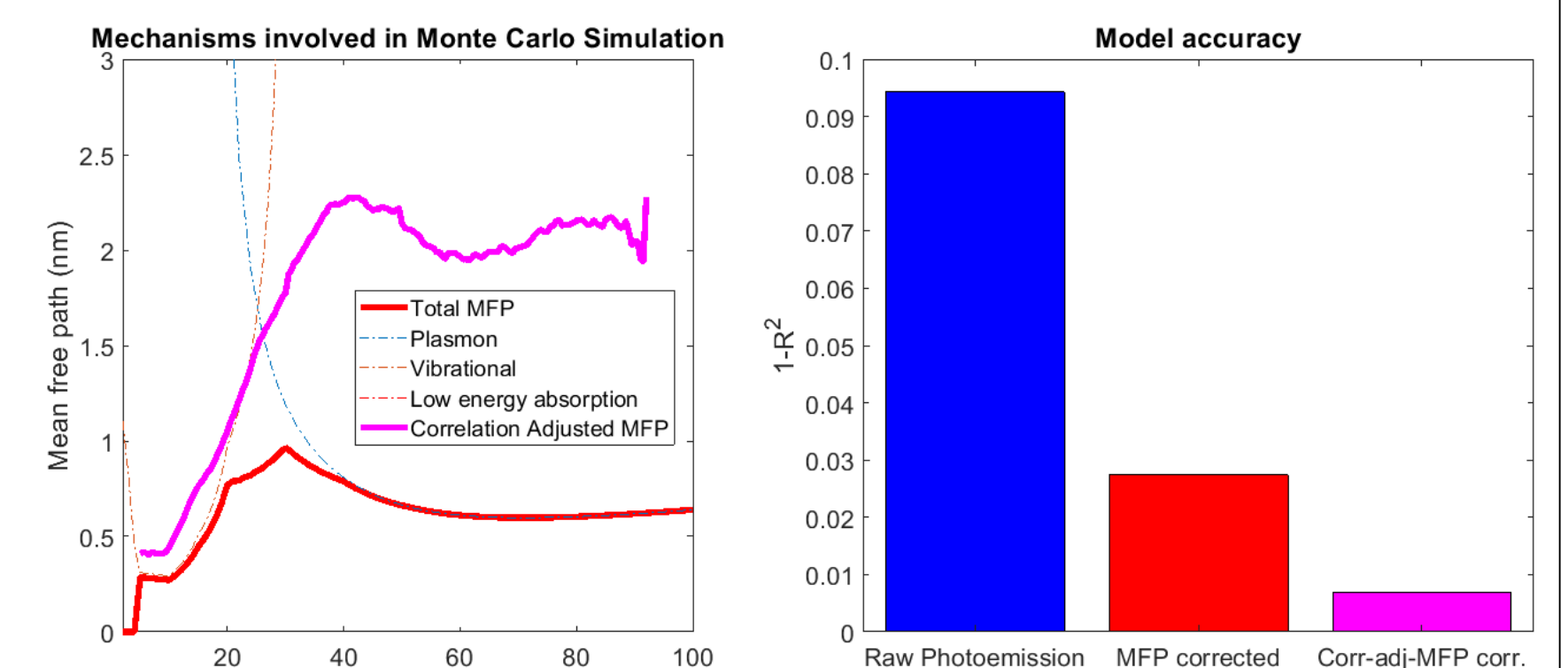
## Forward-dominant scattering

- The internal and photoemission spectra don't match
- Previous solution: division by scattering mean free path  
Henke, B. L., Smith, J. A., and Altwood, D. T., *Journal of Applied Physics* 48(5), 1852-1866 (1977).
- The outgoing direction of scattering events can be correlated with the incoming one
- That results in a longer directional memory
- Effectively a longer mean free path



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## Dividing photoemission spectrum with correlation adjusted mean free path



We're able to recover the internal electron energy spectrum from photoemission data

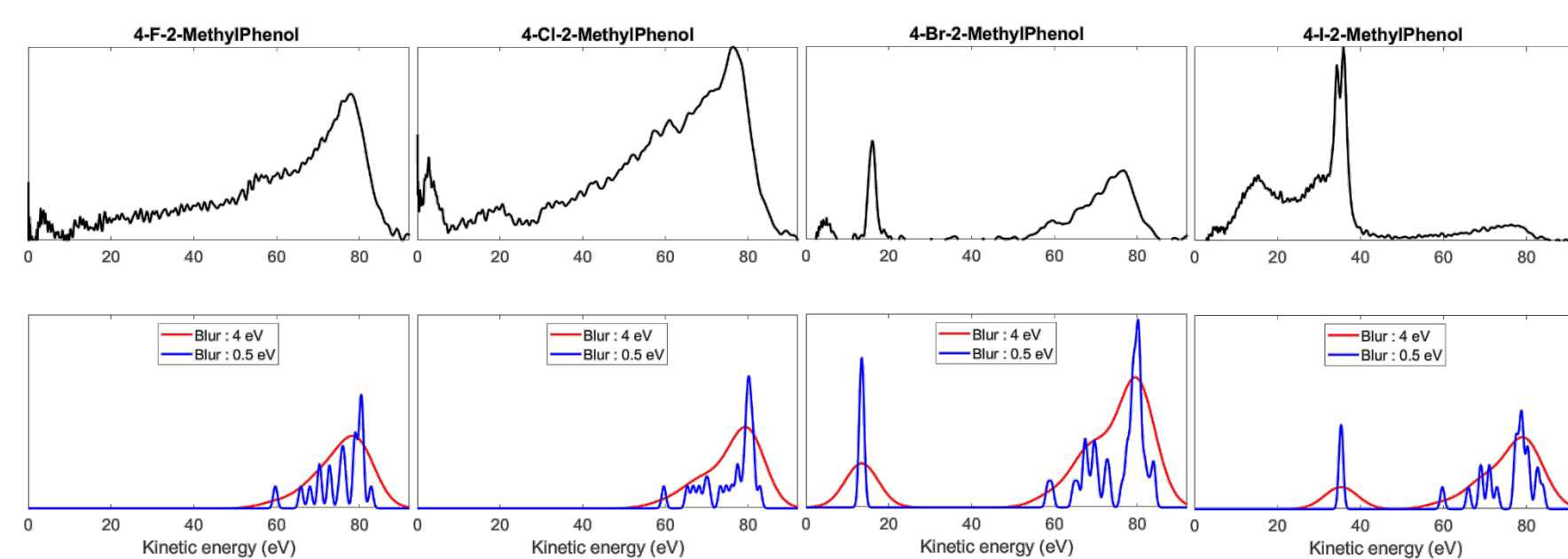
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## Modelling photoemission spectra

Photoemission spectra of prototypical monomers for EUV resists were measured



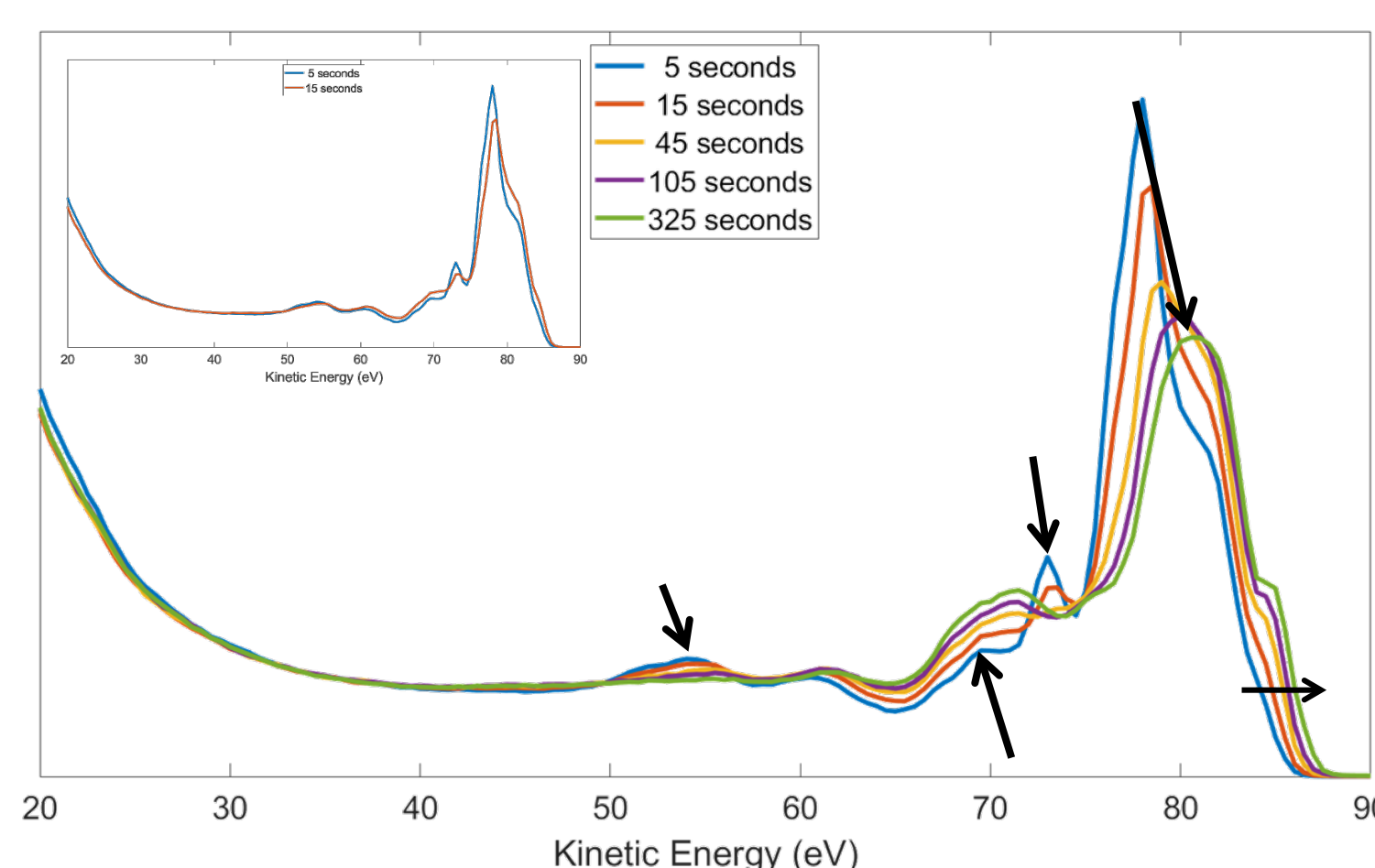
Kostko, Oleg, et al. *The Journal of chemical physics* 149,15 (2018): 154305.



Using Hybrid-DFT calculations, the peak positions are well predicted

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## Avoiding cross-linking



Things happen in tens of seconds  
A 10 second scan preserves the sample reasonably well

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## Future Goals

- Further understanding of EUV radiation chemistry through EUV-induced photo-electron spectroscopy
  - Additional spectroscopic techniques will be explored
- Explore chemical yield/cross-sections as a function of electron energy in EUV resists
  - A two pronged computation/spectroscopy approach will be employed in collaboration with staff at CSD, MSD and Molecular Foundry

### Acknowledgment

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